## **B-1** Nitride Process

### **Representative Organizer**

Hideto MIYAKE (Mie University)

#### Co-organizers

Hiroshi AMANO (Nagoya University)

Yoshio HONDA (Nagoya University)

Satoshi KAMIYAMA (Meijo University)

Motoaki IWAYA (Meijo University)

Makoto MIYOSHI (Nagoya Institute of Technology)

Akihiro WAKAHARA (Toyohashi University of Technology)

Kou MATSUMOTO (TAIYO NIPPON SANSO Corporation)

### Poster Session

March 28 (Sat.)

 $16:45 \sim 18:00$ 

### 16:45 B1-P-01 Radical Assisted Sputtering for GaN Seed Crystal of Na Flux LPE

<sup>1</sup><u>Atsushi Saito</u>, <sup>1</sup>Toshihiro Suzuki, <sup>1</sup>Yasuhiko Akamatsu, <sup>1</sup>Noriaki Tani, <sup>1</sup>Kazuya Saito, <sup>2</sup>Daisuke Matsuo,

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# 16:45 B1-P-02 Characteristics of High-Quality AlN Thick Gilm Grown on c-sapphire Substrates by HVPE Method

<sup>1</sup>Gang Seok Lee, <sup>1</sup>Hunsoo Jeon, <sup>1</sup>Chan Mi Lee, <sup>1</sup>Chan Bin Lee, <sup>1</sup>Sam Nyung Yi, <sup>1</sup>Min Yang,

<sup>1</sup>Hyung Soo Ahn, <sup>2</sup>Suck-Whan Kim, <sup>3</sup>Young Moon Yu, <sup>4</sup>Nobuhiko Sawaki

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3 LED-MCT R&BD CENTER, PUKYONG NATIONAL UNIVERSITY

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### 16:45 B1-P-04 Three Dimensional Selective Growth of Micro-AlGaN/GaN Array Structures

Seunghyun Lee, Hyungsoo Ahn, Min Yang

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#### 16:45 B1-P-05 Generation Behavior of Deep-Level Defects in Ar<sup>+</sup>-Irradiated GaN

<sup>1</sup>Yoshitaka Nakano, <sup>1</sup>Miao-Gen Chen, <sup>1</sup>Daisuke Ogawa, <sup>1</sup>Keiji Nakamura, <sup>2</sup>Retsuo Kawakami, <sup>3</sup>Masahito Niibe

1 CHUBU UNIVERSITY

2 THE UNIVERSITY OF TOKUSHIMA

3 UNIVERSITY OF HYOGO

#### 16:45 B1-P-06L Kinetic Modeling of Group-III Nitride MOCVD

Chun-Jung Chen, Ta-Chin Wei

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# 16:45 B1-P-07L Properties of GaN and InGaN Thin Films Grown on Non-Single-Crystalline Substrates by MBE Using Single or Dual Nitrogen Plasma Cells

<u>Yuichi Sato</u>, Syota Ishizaki, Yoshifumi Murakami, Mohamad Idham, Nur Ain, Yuhei Muraki, Tatsuya Matsunaga DEPARTMENT OF ELECTRICAL AND ELECTRONIC ENGINEERING, AKITA UNIVERSITY

# 16:45 B1-P-08L Investigation on Sputter-Growths of In<sub>2</sub>O<sub>3</sub> Based Under-Electrodes on a Sapphire Substrate for Group-III Nitride Solar Cells

Yuhei Muraki, Syota Ishizaki, Yoshifumi Murakami, <u>Yuichi Sato</u>

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# 16:45 B1-P-09L AIN Deposition on Polycrystalline AIN Substrates by Radical Enhanced Metal Organic Chemical Vapor Deposition

<u>Kazuki Iwamoto</u>, Yi Lu, Osamu Oda, Kenji Ishikawa, Hiroki Kondo, Makoto Sekine, Masaru Hori GRADUATE SCHOOL OF ENGINEERING, NAGOYA UNIVERSITY